

3D Glass forming technology

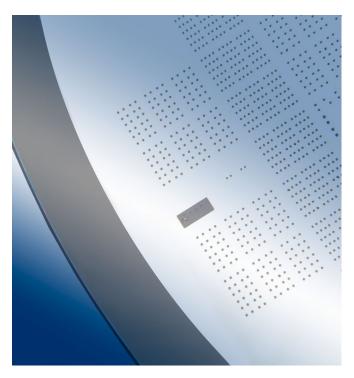
Glass Packages / Inclined Windows / Optical Domes / Lenses / Mirrors

Different structured glass wafer with caps and lenses

Motivation

Fraunhofer ISIT has a wide portfolio of qualified single process technologies available, which were combined to different specific technology process platforms. They form a kind of tool box to realize various applications. One of these process platforms is glass micromachining. Fraunhofer ISIT developed a process based on hot temperature viscous glass micromachining. It is mainly used for the production of micro-lenses and glass packages with inclined window surfaces. Using this process, it is possible to structure glass wafers with high aspect ratios on wafer level. A structured silicon wafer is chosen as so-called primitive form, so glasses must be used whose softening temperature is well below that of silicon. This has the

advantage that the standardized methods to structured silicon wafers of a clean room can be used. The etched structures or cavities correspond later the molded areas in the glass. The structured silicon wafer is then anodically bonded to a glass wafer. In this case, a defined pressure within the cavities is enclosed. When a relative vacuum is enclosed the cavities and the heat treatment takes place under atmospheric pressure, the glass is pressed into the cavities. If an atmospheric pressure is enclosed and the heat treatment takes place under vacuum then the glass is forced out of the cavities. Depending on the application, the glass may now be further processed by grinding and polishing.



Detail view of a glass wafer with silicon vias

Fraunhofer Institute for Silicon Technology ISIT

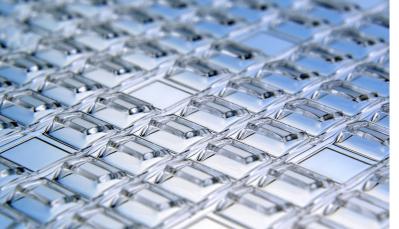
Fraunhoferstraße 1 25524 Itzehoe, Germany

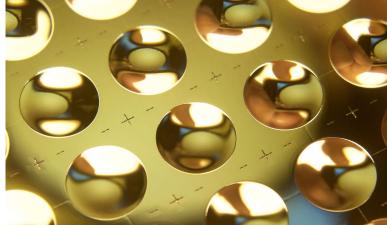
Dr. Vanessa Stenchly Tel. +49 (0) 4821 17-1494 vanessa.stenchly@ isit.fraunhofer.de

www.isit.fraunhofer.de

Fraunhofer ISIT is participant of the







Inclined windows on a 8" glass wafer

Spherical micro mirrors coated with a thin gold layer

Technical data for optical packages

- Packages with planar windows
- Packages with inclined windows with angles up to 15°
- Cavity sizes 1mm up to 10 mm
- Cavity depth 0.1mm up to 4 mm
- Roughness < 1 nm (Ra)
- Window deformation < 100 nm (3.5 mm window size)
- Hermetic sealing

- Proprietary glass forming process
- Anodic wafer bonding
- Material: borosilicate glasses
- Fabrication on 8" wafer

Technology

CTE match to silicon

Schematic of different optical housing conctructions supported by the modular packaging system

Technical data for lenses

- Plano convex, plano concave lenses
- Lens arrays

Lens diameter: 100 μm – 8 mm Sag. height: max: 800 μm ■ ROC: 100 µm – 20 mm

Technical data for Through Glass Vias (TGV)

■ Wafer thickness: < 400 μm

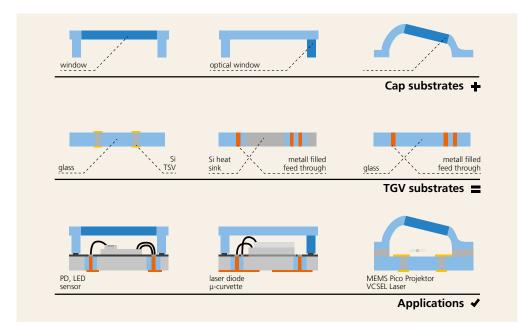
Contact via diameter: < 100 μm

Contact via pitch: (depending on the aspect ratio): < 90 μm (1:4)

Via material: Silicon

Applications

- Wafer Level Opto Packaging
- Hermetic Glass Packages
- Optical Windows
- Lens Arrays
- Micro Optics



Our Service

 Development and production of optical components (mirrors, lenses) on 8" glass substrates

Realization of glass caps for housings of optical microsystems according to customer requirements

- Easy transfer to pilot production
- Access to cost-effective production of microoptical components